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Electron-beam-induced current and cathodoluminescence studies of thermally activated increase for carrier diffusion length and lifetime in n-type ZnO

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While ZnO is suitable for many conventional wide-band-gap semiconductor applications, its optical, electronic, and structural properties offer a significant advantage over other materials, such as GaN and SiC. These characteristics include high exciton binding energy (60 meV, compared to ~25 meV in GaN), transparency to visible radiation, availability of bulk single crystals for use as substrates in epitaxial growth, and possibility of wet chemical processing.1,2

Until recently, the applications potential of ZnO has been hindered by the lack of viable p-type material. While it is relatively easy to obtain n-ZnO, introducing sufficiently shallow acceptor levels is notoriously problematic. Although several heterojunction light-emitting diodes with an n-ZnO active region have been demonstrated,3,4 the quality of such devices suffers due to inevitable crystallographic mismatch at the interface. This limitation is overcome by using all ZnO-based materials. Taking into account the new developments in growth techniques and progress in p-type doping of ZnO, achieving quality, homojunction-based bipolar devices is likely to take place in the near future. In fact, fabrications of Zn$_{10.9}$Mg$_{0.1}$O/ZnO p-n junctions and ZnO p-n homojunctions have already been reported.5

Since the functionality of bipolar devices is based on minority carrier transport, the investigation of minority carrier diffusion lengths and lifetimes in both n- and p-type ZnO, as well as in related materials, is especially timely. Moreover, considering possible applications in high-temperature electronics, the insight into the temperature dependence of ZnO minority carrier diffusion length and lifetime is of great value, especially given the fact that, to the best of our knowledge, the relevant publications on the subject are limited. Minority carrier diffusion length in p-type ZnMgO has been previously reported in Ref. 6. In this letter, we present variable-temperature electron-beam-induced current (EBIC) measurements for minority hole diffusion length in n-type ZnO and combine these measurements with cathodoluminescence (CL) spectroscopy to show that temperature-induced changes in minority carrier transport are associated with increased carrier lifetime in the valence band.

The experiments were carried out on commercially available bulk n-type ZnO samples grown by hydrothermal technique. Room-temperature Hall measurements showed the samples to be weakly n type with an electron concentration of $\sim 10^{14}$ cm$^{-3}$ and a mobility of $\sim 150$ cm$^2$/V s. The samples under investigation were cleaved perpendicular to c plane thus exposing a nonpolar a plane of ZnO. This was motivated by the observations that the latter crystallographic plane results in a better quality of Schottky contacts, as opposed to those deposited on the c plane. Schottky barriers were, therefore, fabricated by electron-beam evaporation of a 100 nm thick Au layer on ZnO a plane and subsequent lift off. The quality of the Schottky contacts is crucial, as it is directly related to the magnitude of EBIC signal. The EBIC technique is the method of choice for determining the minority carrier diffusion length. It is based on measuring the current due to nonequilibrium carriers generated by the electron beam of the scanning electron microscope (SEM) and collected by the built-in field of the Schottky barrier. A detailed description of EBIC technique can be found elsewhere.7–10

A series of variable-temperature EBIC experiments was performed in situ in a Phillips XL30 SEM fitted with a hot stage and an external temperature controller (Gatan). A pair of Au contacts with significantly different areas was used, with the larger area contact being pseudo-Ohmic. At each temperature, several measurements were taken by scanning the beam of the SEM along a line perpendicular to the edge of the Schottky contact, and recording the exponential decay of current. The EBIC signal was processed with a Stanford Research Systems SR570 preamplifier and a Keithley 2000 voltmeter; the data were recorded and fitted using specially designed software to extract the minority carrier diffusion length ($L$). Upon performing a number of measurements, the mean value of $L$ and its standard deviation were determined.

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Temperature dependence of the minority carrier diffusion length and lifetime in bulk n-type ZnO was studied using electron-beam-induced current and cathodoluminescence techniques. The diffusion length was observed to increase exponentially over the temperature range from 25 °C to 125 °C, yielding activation energy of 45±2 meV. Concomitant decrease of the cathodoluminescence intensity for the near-band-edge transition was also observed. The activation energy determined by optical measurements was 58±7 meV. The larger minority carrier diffusion length and smaller luminescence intensity are attributed to the increased lifetime of nonequilibrium holes in the valence band at elevated temperatures. © 2005 American Institute of Physics.

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for every temperature. Note that each line scan was conducted over a previously unexposed area to avoid the influence of electron irradiation.6

In addition to diffusion length measurements, temperature-dependent changes in carrier lifetime were monitored by recording CL spectra in the near-band-edge (NBE) region. A Gatan MonoCL3 CL system is integrated with the SEM, which allows temperature- and wavelength-dependent experiments to be conducted in situ. The peak intensity of the NBE luminescence was monitored to assess the variation in carrier lifetime with increasing temperature. Both EBIC and CL measurements were performed over the range of temperatures from 25 °C to 125 °C. An accelerating voltage of 20 kV was used. As for EBIC experiments, several spectra were recorded at every temperature, each at a new location, after which the mean value of the peak intensity was determined, along with the standard deviation.

Recent technological improvements in ZnO technology prompted vigorous efforts to produce Schottky contacts to ZnO with good rectifying characteristics.11–14 Generally, the challenges in this area are related to low breakdown voltage and high leakage current of such contacts. Figure 1 shows the current-voltage (I-V) characteristics of Au Schottky contacts deposited on the nonpolar a plane of ZnO in linear (top) and logarithmic (bottom) scale.

Table I summarizes the results of EBIC measurements and shows that the diffusion length of minority holes in n-ZnO increases with increasing temperature, T. The increase of L with T is not unique for this semiconductor. Similar trends were previously observed in GaAs (Ref. 15) and later in GaN epitaxial layers.7 In all cases, this increase was exponential with temperature and was modeled with the following expression:15

\[
L = L_0 \exp \left(-\frac{E_A}{2kT}\right),
\]

where \(L_0\) is a scaling factor, \(E_A\) is the activation energy, and \(k\) is the Boltzmann constant. Figure 2 shows the experimental results for n-ZnO obtained in this work and the fit using Eq. (1), which yields an activation energy of 45±2 meV. The latter parameter represents carrier delocalization energy, since it determines the increase of the diffusion length due to reduction of recombination efficiency (see discussion below).15 The smaller the activation energy, the more efficient the thermally activated escape of captured carriers at any fixed temperature.

The temperature-induced increase of \(L\) may be attributable to the growing lifetime of nonequilibrium minority holes in the valence band, as illustrated by the following expression:

\[
L = \sqrt{D\tau},
\]

where \(\tau\) is carrier lifetime and \(D\) is the diffusivity. Note that the temperature dependence of diffusivity and its effect on diffusion length are addressed later in the letter.

The role of increasing carrier lifetime is supported by the results of CL measurements, which are presented in Fig. 3. The inset of Fig. 3 shows a CL spectrum in the vicinity of the NBE transition at 385 nm (3.22 eV). It was observed that the peak intensity, \(I\), of NBE luminescence decays systematically with increasing temperature, providing direct evidence that the number of recombination events decreases. The decay proceeds exponentially according to the equation below:16

\[
I = I_0 \exp (-\frac{E_A}{2kT}),
\]

where \(I_0\) is a scaling factor, \(E_A\) is the activation energy, and \(k\) is the Boltzmann constant. Figure 2 shows the experimental results for n-ZnO obtained in this work and the fit using Eq. (1), which yields an activation energy of 45±2 meV. The latter parameter represents carrier delocalization energy, since it determines the increase of the diffusion length due to reduction of recombination efficiency (see discussion below).15 The smaller the activation energy, the more efficient the thermally activated escape of captured carriers at any fixed temperature.

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\[
I = I_0 \exp (-\frac{E_A}{2kT}),
\]
where $A$ and $B$ are scaling factors, and $E_A$ is the activation energy, similar in nature to that in Eq. (1). Based on the fit shown in Fig. 3, the activation energy was determined to be $58 \pm 7$ meV. This energy is in reasonable agreement with that obtained by variable-temperature EBIC measurements, which suggests that the same underlying process is responsible for both the increase in the diffusion length and the CL intensity decay. This process is outlined below.

The increase in minority hole lifetime in the valence band is likely associated with a smaller recombination carrier capture cross section for this carrier at elevated temperatures. In GaAs, for example, a detailed analysis for the temperature dependence of the capture cross section indicates an order of magnitude decrease in recombination efficiency, measured in terms of an “effective capture radius,” in the temperature range from 100 to 300 K.\textsuperscript{15} Nonequilibrium electron-hole pairs are generated by the beam of the SEM, and subsequently annihilated by recombining with each other. Since the hole capture cross section is inversely proportional to temperature,\textsuperscript{15,17} the frequency of the recombination events (and, hence, the CL intensity) decreases as the temperature is raised. This means that nonequilibrium holes exist in the valence band for longer periods of time and, consequently, diffuse longer distances before undergoing recombination.

Note that carrier diffusivity, $D$, is also a temperature-dependent quantity and, therefore, can affect the diffusion length. On the other hand, it has been demonstrated for $n$-ZnO that the mobility, $\mu$, of the majority carriers decreases in the temperature range of our experiments by about a factor of 2.\textsuperscript{18} Assuming that the mobility of the minority carriers exhibits the same behavior,\textsuperscript{17} and using the Einstein relation ($D = \mu kT / q$, where $q$ is elementary charge), it is clear from Eq. (2) that the value of the diffusion length is dominated by the growing lifetime of minority holes. From the Einstein relation, the above-referenced difference in mobility translates to about a 30% decrease in diffusivity at 125 °C as compared to 25 °C. Based on a 30% difference in diffusivity and using experimentally obtained values of diffusion length, we conclude that the lifetime of minority holes at 125 °C is nearly 2.5 times greater than at room temperature.

In conclusion, temperature-dependent transport properties of minority carriers were studied in $n$-ZnO. The minority carrier diffusion length was observed to increase, while the CL intensity of the NBE transition decreased, indicating that the lifetime of nonequilibrium carriers in the band is greater at elevated temperatures. Activation energies obtained from both experimental techniques were in good agreement with each other, which suggests that both observations are manifestations of the same phenomenon.

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